

PN JUNCTION DIODE

⇒ When a P-type semiconductor is joined to an N-type semiconductor, the contact surface is called PN junction or PN diode.

⇒ The voltage across PN junction can be applied in two ways.

i) Forward Biasing

ii) Reverse Biasing.

⇒ Formation of PN junction

The n-type material has high concentration of free electrons and p-type material has high concentration of holes.

⇒ At the junction, there is a tendency for the free electrons of the n-type to diffuse over to the P-side and holes from the P-side to the N-side.

⇒ This process is called diffusion.

⇒ A barrier is set up against further movement of charge carriers (holes and free electrons) -

called Potential barrier or Junction barrier (V_B)

⇒ V_B is of the order of 0.1 V to 0.3 V

⇒ As the mobile charges have been depleted in this region it is called depletion layer

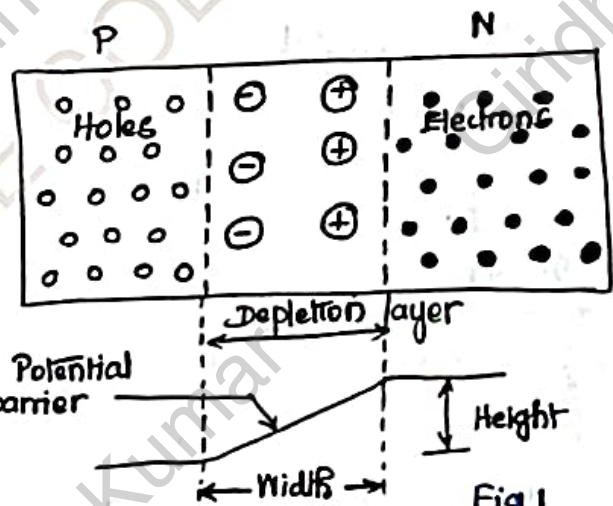


Fig 1

i) ZENER BREAKDOWN

- ⇒ The breakdown using heavily doped P and N regions, direct rupture of covalent bonds takes place because of the strong electric field at the junction of the PN diode.
- ⇒ The new electron-hole pairs so created increase the reverse current in a reverse biased PN diode.
- ⇒ Due to heavy doping of p and n regions, the depletion region width becomes very small and for an applied reverse bias of $6V$ or less.
- ⇒ The field across the depletion region becomes very high of the order of $2 \times 10^7 V/m$.

ii) AVAILANCE BREAKDOWN

- ⇒ In reverse biased diode, a thermally generated carrier falls down the junction barrier and acquires energy from the applied voltage.

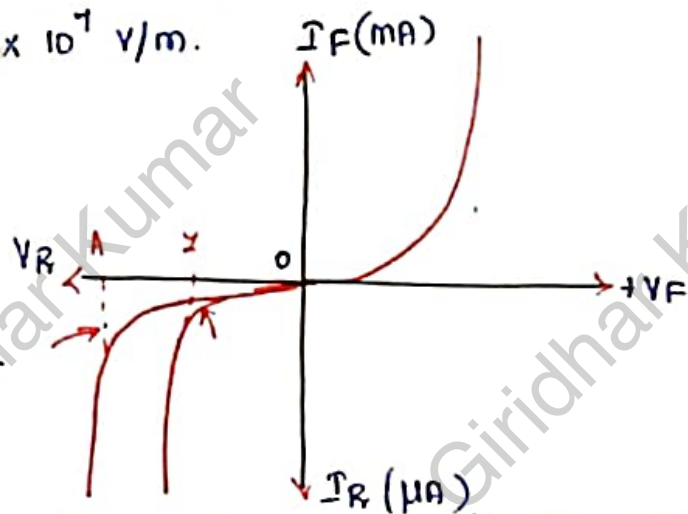
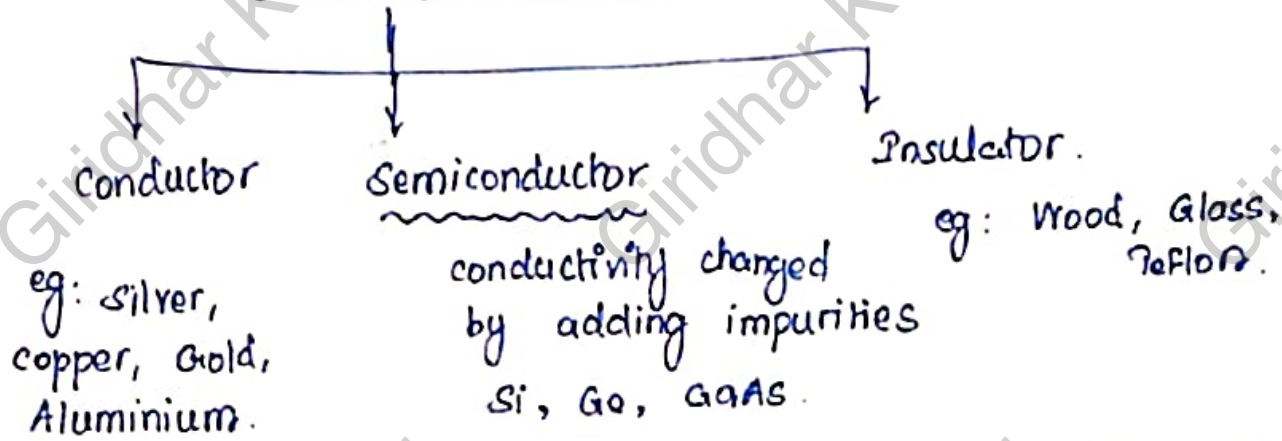


Fig 2: Breakdown in PN junction diode.

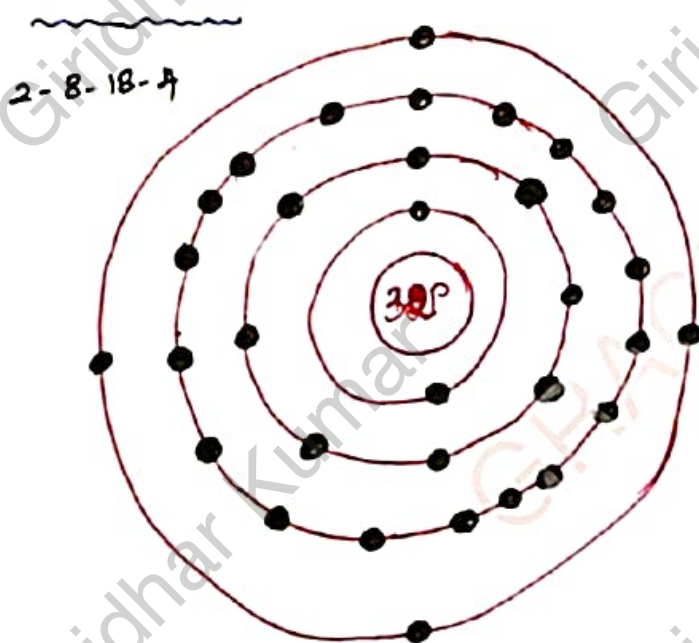
- ⇒ The sufficient kinetic energy to disrupt a covalent bond, at this carrier collides with crystal. - known as impact ionization.
- ⇒ A new electron-hole pair created, in addition to the original carrier. - The new carriers in turn, acquire enough energy from the applied field - collide with another crystal ion and create still another electron-hole pair. - this is a cumulative process and is known as avalanche multiplication.

Types of Materials



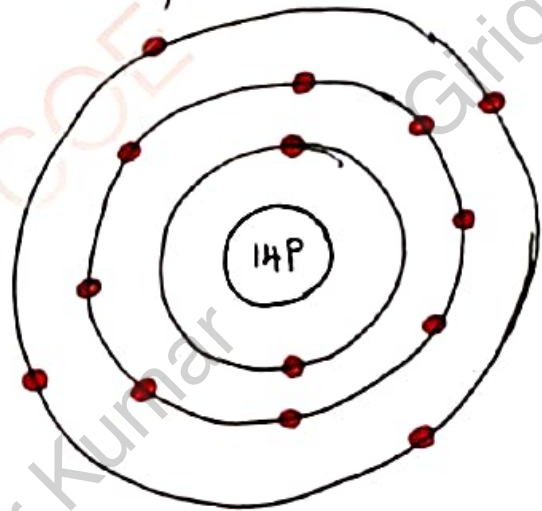
Silicon - 14 electrons are arranged in the order $2n^2$
 n - orbit number.

Germanium - 32



Silicon - 14

2-8-4



Two types of flow in semiconductor

- 1) Flow due to electrons
- 2) Flow due to holes

semiconductor

Intrinsic

Extrinsic

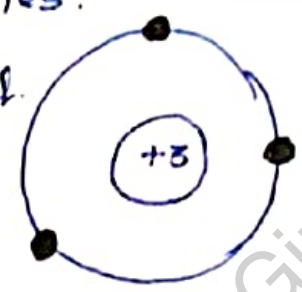
→ p-type

→ n-type

Doping - process of adding impurities.
 ⇒ can change the electrical properties of material.

Trivalent atoms -
 p-type semiconductor

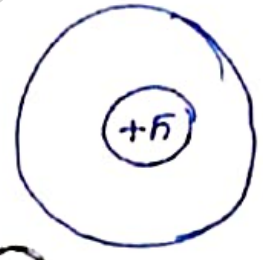
- Aluminium
- Boron
- Gallium



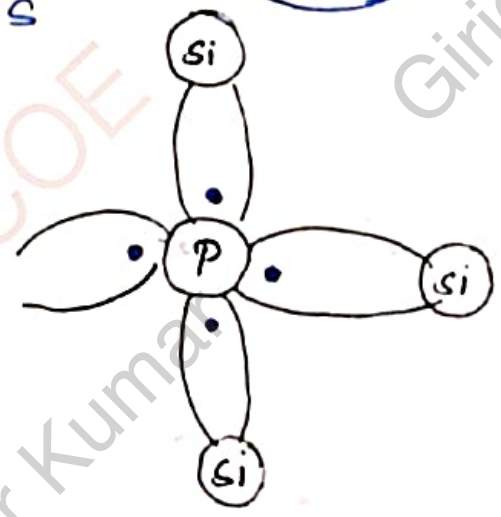
⇒ every trivalent atom creates 1 hole.
 ⇒ these trivalent atoms → acceptor atom.

Pentavalent atom
 n-type semiconductor.

- Arsenic
- Antimony
- Phosphorus



⇒ this process creates
 unbound electrons in
 conduction band.



Energy level - range of energies that an electron may possess in an atom.

Energy band - The electrons in the same orbit exhibit different energy levels. The grouping of this different energy levels is known as energy band.

Types of energy bands

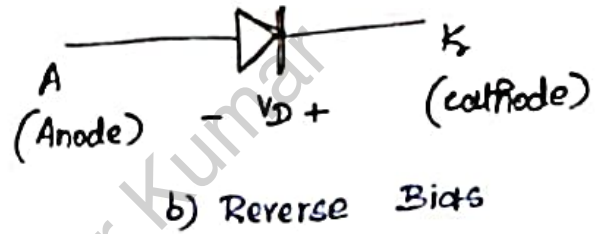
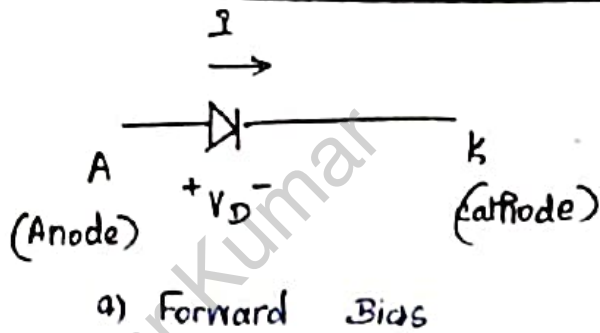
- 1) Valence band $E_g = 0$
- 2) conduction band $E_g \approx 4V - 8eV$
- 3) Forbidden band $E_g > 10eV$

conductor
 Insulator

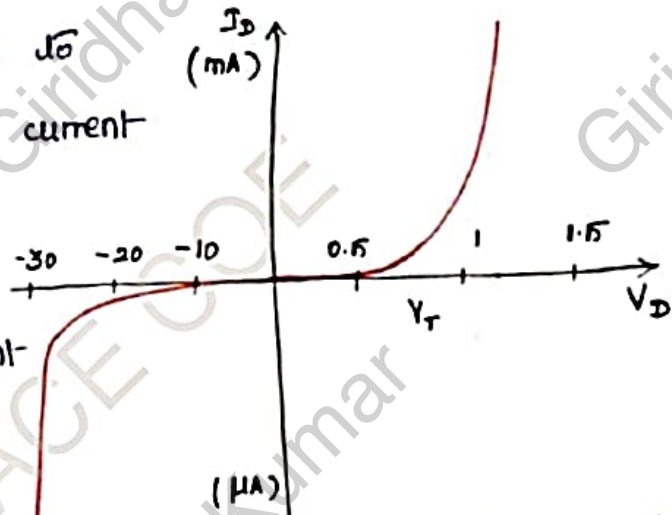
EC3353_EDC semiconductor 0.1 - 3eV

The result is a large reverse current at an almost constant voltage drop and avalanche breakdown takes place.

4.2. V-I CHARACTERISTICS OF A DIODE



⇒ V-I characteristics helps to analyze the voltage and current in the diode.



⇒ We know that the resistor is a linear element and hence the V-I characteristic is also linear.

⇒ Unlike, the resistor, the diode is a non-linear element and hence the V-I characteristic is also non-linear.

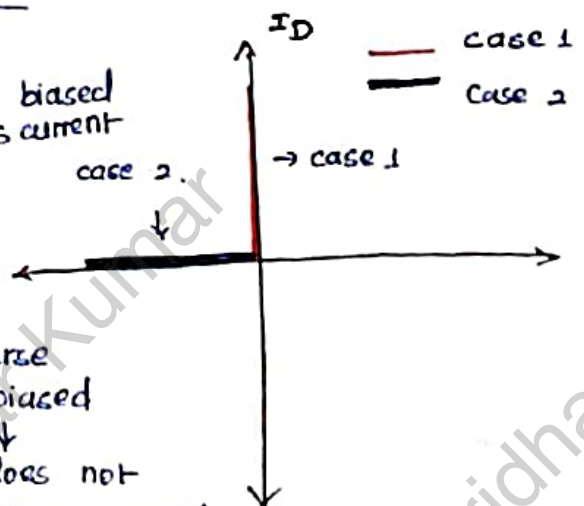
⇒ V-I characteristic of ideal diode

case 1: Applied voltage is positive
→ Forward biased allows current

+ V_D - ⇒ + V_D -

case 2: Applied voltage is negative,
→ Reverse biased does not allow current.

- V_D + ⇒ - V_D +



⇒ An ideal diode starts conducting current in the forward bias condition even when a very small voltage of 0.1 V is applied.